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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Koji NOZAKI et al.**

Group Art Unit: **1752**

Serial No.: **09/015,287** ✓

Examiner: **CHU, JOHN S Y**

Filed: **January 29, 1998**

Confirmation No.: **5544**

For: **POLYMER COMPOUND FOR A CHEMICAL AMPLIFICATION  
RESIST AND A FABRICATION PROCESS OF A SEMICONDUCTOR  
DEVICE USING SUCH A CHEMICAL AMPLIFICATION RESIST**

Attorney Docket No.: **980055**

Customer Number: **38834**

**AMENDMENT UNDER 37 C.F.R. §1.312**

**Box Issue Fee**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

September 30, 2004

Sir:

Applicant received a Notice of Allowance dated September 20, 2004 in connection with the above-identified application. It is respectfully requested that the following amendment be made to the specification of this application:

**Amendments to the Specification** begin on page 2 of this paper.

**Remarks** begin on page 7 of this paper.